

<b>Substitute for form 1449A/PTO (modified)</b>  <b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b>  (Use as many sheets as necessary)  Page 1 of 5	<b>Application Number</b>	10/595678
	<b>Filing Date</b>	15-OCT-2004
	<b>First Named Inventor</b>	NODA, KAZUKI
	<b>Confirmation Number</b>	4637
	<b>Attorney Case Number</b>	59018US007

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